



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Date Application of :

Hatakeyama et al.

Group Art Unit: 1752

Serial No.: 09/994,808

Examiner: LEE, Sin J.

Filed: November 28, 2001

For: AMINE COMPOUNDS, RESIST COMPOSITIONS AND PATTERNING PROCESS

SUPPLEMENTAL REPLY

Mail Stop Non Fee Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

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DEC 16 2003

SIR:

TC 1700

Further to the Reply filed on December 10, 2003, please amend the claims as follows.

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments begin on page 12 of this paper.